Diffraction microscopy - from millimeter to nanometer

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The need for spatial resolution

- Most samples show internal variation:
 - Composition
 - Crystal structure
 - Strain
 - ...
- X-ray methods have traditionally had poor real space resolution
- New synchrotrons and new X-ray optics allow focusing below 100 nanometer



The need for nanoscale resolution

- Nanostructured materials have unique properties.
- Polycrystalline materials such as metals are nanostructured, with grain sizes from 10 nm to 10 µm
- Measuring *individual nanostructures* or *individual grains* gives a different insight compared with low-resolution, averaging methods





Strain in a crystal from stress or lattice mismatch

- A crystal under stress will be strained
- On an atomic level, this will change the atomic distances
- Strain can also come from lattice mismatch in a heterostructure







Other sources of shift in lattice distance

- Compound composition, e.g. in Si_xGe_{1-x}
- Piezoelectric fields
- Heating / cooling (thermal expansion)
- Manufacturing damage, e.g. from cutting
- Surface stress

All of these change the lattice, which can be measured by XRD => We can use XRD as a gauge of other processes

 These effects generally <u>vary in space</u>. How can we characterize this?

Effect of strain on powder XRD / WAXS





Change can be quantified and converted to strain

Focused X-rays



Scanning X-ray diffraction (XRD)



- Focused X-ray beam
 => local XRD
- Investigate the local crystal structure
- Create maps of local lattice plane distance and direction
- Spatial resolution limited by focus size



X-ray contrast mechanisms



X-ray fluorescence



XRF energy: Elemental fingerprint



X-ray fluorescence (XRF)

- The emitted XRF photons have energies which are characteristic for the element
- List sorted by element here <u>http://www.med.harvard.edu/jpnm/physics/refs/xrayemis.html</u>
- Tables can be found for instance in the X-ray data booklet, which can also be found on <u>http://xdb.lbl.gov/</u>

Element	Κ <i>α</i> ₁	K <i>α</i> ₂	K <i>β</i> 1	L <i>a</i> 1	$L\alpha_2$	$L\beta_1$	$L\beta_2$	L'n	$M \alpha_1$
63 Eu	41,542.2	40,901.9	47,037.9	5,845.7	5,816.6	6,456.4	6,843.2	7,480.3	1,131
64 Gd	42,996.2	42,308.9	48,697	6,057.2	6,025.0	6,713.2	7,102.8	7,785.8	1,185
65 Tb	44,481.6	43,744.1	50,382	6,272.8	6,238.0	6,978	7,366.7	8,102	1,240
66 Dy	45,998.4	45,207.8	52,119	6,495.2	6,457.7	7,247.7	7,635.7	8,418.8	1,293
67 Ho	47,546.7	46,699.7	53,877	6,719.8	6,679.5	7,525.3	7,911	8,747	1,348
68 Er	49,127.7	48,221.1	55,681	6,948.7	6,905.0	7,810.9	8,189.0	9,089	1,406
69 Tm	50,741.6	49,772.6	57,517	7,179.9	7,133.1	8,101	8,468	9,426	1,462
70 Yb	52,388.9	51,354.0	59,370	7,415.6	7,367.3	8,401.8	8,758.8	9,780.1	1,521.4
71 Lu	54,069.8	52,965.0	61,283	7,655.5	7,604.9	8,709.0	9,048.9	10,143.4	1,581.3 ¹

Table 1-2. Energies of x-ray emission lines (continued).

Example spectrum from Silicon drift detector



XRF detection limit

- The lowest detectable concentration is called the detection limit
- Depends on:
 - Element (high Z better)
 - Detector
 - Primary X-ray flux & energy
 - Overlapping XRF lines from other elements.
 - => Sample-dependent
- Often in the parts per million (ppm) range – usually much better than EDS (~%)

	Material	Elements	LOD (PPM)	Element	LOD (PI
		Mg	8976	Sn	25.3
		AI	309	Sb	22.3
		Si	864	Th	5
		Р	212	Nb	3.7
		S	170	Ba	17
		CI	126	Ba	12
		ĸ	84	W	15
		Ca	45	Au	20
		Ti	88	Pt	15
		V	10	Rh	15
		Cr	15	Hg	5
	Take	Mn	10	Sc	35
	example of	Fe	7	Y	4.5
	SO2 for	Co	7	La	35.7
	Mineral and	Ni	5	Се	26.4
	rear earth	Cu	4	Pr	36
•	elements)	Zn	5	Nd	35.7
		As	1.5	Pm	35
		Pb	3.5	Sm	34.5
		Br	2	Eu	34.7
		Rb	1.5	Gd	34
		Sr	2.3	Tb	33.2
		Zr	1.2	Dy	32.5
		Nb	1.1	Но	32
		Mo	15	Er	31.3
Exa	mple:	Ag	10	Tm	30
Han	dheld XRF	Cd	20	Yb	28.5
dovi		Sn	25	Lu	27
devi	ce, soli				

Scanning XRF

- Sample scanned in focused beam
- XRF spectrum measured at each point
- Composition evaluated, creating a 2D map
- Resolution limited by focus





J. Deng, D. J. Vine, S. Chen, Q. Jin, Y. S. G. Nashed, T. Peterka, S. Vogt, and C. Jacobsen, "X-ray ptychographic and fluorescence microscopy of frozen-hydrated cells using continuous scanning" Scientific Reports 7 (1), 445 (2017) 10.1038/s41598-017-00569-y

Nano-XRF of ore from Liikavaara Östra Cu-(W-Au) deposit



Image size 4x5 µm

M. Warlo, G. Bark, C. Wanhainen, I. McElroy, A. Björling, and U. Johansson, "*Extreme-resolution synchrotron X-Ray fluorescence mapping of ore samples*" **Ore Geology Reviews** 140, 104620 (2022) https://doi.org/10.1016/j.oregeorev.2021.104620

XRF on new Mars 2020 rover

- Focused X-ray source (25 kV)
- Scanning micro-XRF
- Spatial resolution 300 µm





https://astrobiology.nasa.gov/news /pixl-a-new-nasa-instrument-forferreting-out-clues-of-ancient-lifeon-mars/

Example with micrometer resolution: Brazed joint

- Collaboration between Filip Lenrick, LTH, and AlfaLaval.
- Two metals joined by brazing, to create heat exchangers
- Cross-sectional foil
- Applied stress until failure
- Data analysis in the summer by students. Still work in progress!





Experimental setup at DanMax

- Vertical stress
- Measure in transmission
- Scanning X-ray diffraction / WAXS + XRF





XRF maps

Step size 10 micrometer



Nickel: 7.45 keV peak

Molybdenum: 17.45 keV peak

Chromium: 5.39 keV peak

Iron: 6.38 keV peak

XRF maps, details

Step size 10 micrometer





Nickel: 7.45 keV peak Molybdenum: 17.45 keV peak Chromium: 5.39 keV peak

Iron: 6.38 keV peak

X-ray diffraction (XRD): Fe (111)

Map of intensity for each position



Other peaks in XRD



- These peaks could disappear in a lowresolution averaging method
- Spatial distribution crucial to understand the material!





Applied stress experiment

Small stress



High stress



After failure



Nanobeam investigations: Inconel White layer

- White layer formed in Inconel 718 super alloy by machining
- Thin lamella extracted by focused ion beam (FIB)
- Investigated at NanoMax beamline,
 ~ 90 nm beam
 - Marcal et al "Materials

L. Marcal, et al., " Materials & Design 239, 112789 (2024) https://doi.org/10.1016/j.matdes.202 4.112789





Scanning X-ray diffraction

XRD: γ/γ' (111)



XRD: γ/γ' (002)





Nanobeam experiment at NanoMax: Strain within single crystal nanowire transistor



In situ imaging of InO single grain growth

- 3D imaging single grain growth from ~100 nm to ~500 nm
- Shape and strain



D. Dzhigaev, et al., "*Three-dimensional in situ imaging of single-grain growth in polycrystalline In2O3:Zr films*" Communications Materials 3 (1), 38 (2022) http://doi.org/10.1038/s43246-022-00260-4

Summary

- Synchrotrons can now give real-space resolution ranging from 10 micron down to <100 nm
- Spatial resolution can give new, often unexpected, insight into materials
- Local measurements can discover rare phases
- Measuring composition with XRF can be important to understand XRD results
- Can be combined with operando / in situ setups





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